

Docket No.: 200062US0XPC



IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF:

Kenichi HIROTA, et al.

: GROUP ART UNIT: 1746

SERIAL NO: 09/700,704

FILED: NOVEMBER 24, 2000

: EXAMINER: KORNAKOV, M.

FOR : CLEANING FLUID AND CLEANING METHOD FOR COMPONENT OF
SEMICONDUCTOR-TREATING APPARATUS

AMENDMENT AND REQUEST FOR RECONSIDERATION

ASSISTANT COMMISSIONER FOR PATENTS
WASHINGTON, D.C. 20231

RECEIVED
JUL 16 2002
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SIR:

In response to the Office Action mailed April 10, 2002, Applicants request
reconsideration of the above-identified application in view of the following amendment and
remarks.

IN THE CLAIMS

✓
Cancel Claim 2.

Please amend the claims as shown in the marked-up copy attached to read as follows:

A1 Sub B1 1. (Amended) A composition comprising N-methyl-2-pyrrolidone, ethylene glycol
monobutyl ether, a surfactant, and water.

A2 Sub B2 3. (Amended) The composition according to claim 1, wherein the water concentration
is 5 to 20 wt%.

A3 Sub B2 4. (Twice Amended) The composition according to claim 1, wherein the surfactant
concentration is 0.1 to 1.0 wt%.

A4 Sub B2 5. (Amended) The composition according to claim 4, wherein the surfactant contains
fluorine.